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APPLICATION NO.	NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/658,840	09/09/2003		Ralph R. Dammel	2003US301/CIP 3016		
7590 03/24/2005			EXAMINER			
Sangya Jain			CHU, JOHN S Y			
Clariant Corpor 70 Meister Ave			ART UNIT	PAPER NUMBER		
Somerville, N.			1752			
				DATE MAILED: 03/24/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Applica	tion No.	Applicant(s)				
	er 4	10/658	840	DAMMEL ET AL.				
Off	fice Action Summary	Examin	er	Art Unit				
	•	John S.		1752				
The fi Period for Repl	MAILING DATE of this communic Y	ation appears on t	he cover sheet with the d	correspondence address				
THE MAILIN - Extensions of the after SIX (6) Minus of the period form of the series o	NED STATUTORY PERIOD FOR ITS COMMUNICATION OF THIS COMMUNICATION OF THIS COMMUNICATION OF THE PROVINCE OF THE	CATION. f 37 CFR 1.136(a). In no nication. days, a reply within the sutory period will apply and ill, by statute, cause the a	event, however, may a reply be tir tatutory minimum of thirty (30) day will expire SIX (6) MONTHS from polication to become ABANDONE	nely filed /s will be considered timely. I the mailing date of this communication. ED (35 U.S.C. § 133).				
Status	:							
1)⊠ Respo	nsive to communication(s) filed	on 12 January 20	005.					
	This action is FINAL . 2b)⊠ This action is non-final.							
3)☐ Since								
	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition of (Claims							
4)⊠ Claim(s) <u>1-27</u> is/are pending in the ap	plication.						
	4a) Of the above claim(s) <u>18-27</u> is/are withdrawn from consideration.							
	Claim(s) is/are allowed. Claim(s) 1-17 is/are rejected. Claim(s) is/are objected to.							
<u> </u>								
	s) are subject to restricti	on and/or election	requirement.					
Application Par	pers							
9)∏ The sp	ecification is objected to by the	Examiner.						
	awing(s) filed on is/are:		h) objected to by the	Evaminer				
	int may not request that any object		· ·					
	ement drawing sheet(s) including t		•	• •				
	th or declaration is objected to			* *				
Priority under 3		, =		770001701701117170702.				
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	viedgment is made of a claim fo	or foreign priority u	inder 35 U.S.C. § 119(a)-(a) or (f).				
	b) Some * c) None of:							
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	application from the Internation attached detailed Office action			. d				
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Attachment(s)	:							
	rences Cited (PTO-892)		4) Interview Summary					
	sperson's Patent Drawing Review (PT		Paper No(s)/Mail Da	ate atent Application (PTO-152)				
	sclosure Statement(s) (PTO-1449 or P lail Date <u>9/9/03,10/1, 11/16</u> .		6) Other:	акт Аррікацоп (РТО-152)				

DETAILED ACTION

This Office action is in response to the election received January 12, 2005.

1. Applicant's election with traverse of the invention elected in the reply filed on January 12, 2005 is acknowledged. The traversal is on the ground(s) that injection molding uses powder or granulated thermoplastics and applicants have amended the claims to include a solvent making the composition as solvent. This is not found persuasive because the claim as presented could contain minuscule amounts of solvent so as to remain a solid material that can be used in injection mold.

The examiner however will rejoin the method claims upon indication of allowance of the product claims, if the scope to the product and the use of the product in the method claims are identical. This practice being based on In re Ochiai.

The requirement is still deemed proper and is therefore made FINAL.

Claim Rejections - 35 USC § 112

- 2. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 3. Claims 1-17 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 4 fails to further limit the polymer unit of claim 1, structure 1. It is not clear how those structures in claim 4 relate to structure 1 in claim 1, because the cyclic groups are not clear as to how they further limit the linear of structure 1.

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Claim 7 " n" is undefined.

Claim 10 is not clear as to which polymer the claim refers (polymer having structure 1).

Claims 11 are unclear as to how named polymers reflect structure 1 of claim 1 wherein structure 1 has a carboxyl group and the nomeclature in claim 11 fails to name a carboxyl type structure in the defined polymer (ester, carbonyloxy, etc.)

Claim 12 and 13 fail to further limit the scope of claim 1 and is an improper dependent claim, because the polymer to which claim 12 refers fails to mention structure 1 and goes on to recites polymer mixtures.

Correction is necessary.

Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 5. Claims 1-17 are rejected under 35 U.S.C. 102(e) as being clearly anticipated by. as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over ITO et al '219.

The claimed invention is drawn to the following:

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1(currently amended). A photoresist composition comprising a photoacid generator, a solvent and at least one novel polymer comprising at least one unit as described by structure 1,

$$\begin{pmatrix} R_{1} \\ X \\ X \\ M_{m} \\ R_{f} - C - R_{2} \\ 0 \\ C - R_{4} \\ C - R_{4} \end{pmatrix}_{p}$$

$$\begin{pmatrix} R_{3} - C - R_{4} \\ C - R_{4} \\ C - C - R_{4} \\ C - C - R_{5} \\ C - C - R_$$

where, either

- (i) R_1 is an aliphatic cyclic unit of a polymer, R_2 is selected from H, F, (C_1 - C_8)alkyl, (C_1 - C_8)fluoroalkyl, cyclofluoroalkyl, and (CR_3R_4)p(CO)OR₅, and R_1 is selected from F, H, (C_1 - C_8)alkyl, or a fully or partially fluorinated alkyl, and cyclofluoroalkyl, or
- (ii) R_1 and R_2 combine to form an aliphatic cyclic unit of a polymer, and R_1 is selected from F, H, (C_1-C_0) alkyl and a fully or partially fluorinated alkyl, and cyclofluoroslkyl, or
- (ii) R_1 and R_1 combine to form an aliphatic cyclic unit of a polymer, and R_2 is selected from H, F, (C_1-C_8) alkyl, (C_1-C_8) fluoroalkyl, cyclofluoroalkyl, and $(CR_3R_4)p(CO)OR_5$; and,

 R_3 and R_4 are independently H, F, (C₁-C₈)alkyl, (C₁-C₈)fluoroalkyl, cyclofluoroalkyl, (CR₃R₄)p(CO)OR₅, R₃ and R₄ may combine to form an alkylspirocyclic or a fluoroalkylspirocyclic group,

X is selected from (C_1-C_6) alkylene, (C_1-C_6) fluoroalkylene, $O(C_1-C_6)$ alkylene, $O(C_1-C_6)$ fluoroalkylene, cycloalkyl and fluorinatedcycloalkyl,

R₅ is H or an acid labile group, m=0-1, and p=1-4.

ITO et al discloses a chemically amplified photoresist composition comprising the following teaching in column 5, lines 1-17:

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wherein m is zero or 1, r is zero or 1, L is an alkylene or oxyalkylene linking group, R¹ is linear or branched fluoroalkyl, R² is linear or branched alkyl or fluoroalkyl, and R³ is hydrogen, alkyl (preferably lower alkyl), —C(O)—R, —CH₂—C(O)OR, —C(O)OR or Si(R)₂ wherein R is alkyl, preferably lower alkyl (e.g., R³ may be —C(O)OC(CH₂)₃, —CH₂C(O)OC(CH₂)₃, —C(O)CH₃, or —Si(CH₃)₃), and at least one additional monomer having the atructure (II)

wherein this structure anticipates the claimed invention

having the claimed unit of structure 1.

Applicants are further directed to Example 5 in column

(1)

15, line 42 – column 16, et seq. wherein the following monomer is made:

This monomer is used to prepare a polymer as disclosed in claims of ITO et al. In addition the copolymer made in ITO et al is used in composition comprising an acid generator, see <u>claim 24</u>, <u>column 19</u>, line 63 – column 20, line 29.

Alternatively, it would have been *prima facie* obvious to one of ordinary skill in the art of photoresist compositions to select the preferred side group as recited in column 15, line 16 as seen here: —CH₂C(O)OC(CH₂)₃, —C(O)CH₃, and reasonably expect same or similar results with respect to transparency in deep UV light.

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6. The prior art made of record and not relied upon is considered pertinent to applicant's

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disclosure. NAITO et al is cited of interest to disclose photoresist composition comprising

fluoroalkyl groups off of cyclic alkylene monomers.

7. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Examiner Chu whose telephone number is (571) 272-1329. The

examiner can normally be reached on Monday - Friday from 9:30 am to 6:00 pm.

The fax phone number for the USPTO is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the Group receptionist whose telephone number is (571) 272-1700.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PMR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jøhn S. Chu

Primary Examiner, Group 1700

J.Chu

March 20, 2005